

# **DX Short Pulse Series**

**DX Nanosecond Lasers** 

### Solid State DPSS, TEM<sub>00</sub>, Q-Switched Lasers

For over 30 years, Photonics Industries' DX Series short-pulse nanosecond lasers have set the standard for precision and performance in industrial systems. Compact and powerful, these lasers feature pulse widths as short as ~10 nanoseconds and repetition rates up to an impressive 1 MHz, delivering unparalleled speed and accuracy. Designed for high-production throughput, they are the ideal choice for industries that demand consistent, precision quality at scale.

With tens of thousands of units shipped worldwide, the DX Series has earned a reputation for reliability and innovation. Its patented intracavity harmonic generation technology eliminates harmful indexing on harmonic crystals, ensuring peak performance and extended lifespan. Whether your production needs call for precision micro-machining or high-output manufacturing, the DX Series is engineered to exceed your expectations and elevate your operations.



#### **APPLICATIONS**

- Semiconductor Wafer Marking
- Silicon, PERC and Solar Cell
- PCB & Polymer Cutting & Drilling
- Glass and Ceramics Processing
- Surface Cleaning and Ablation
- Microelectronics Fabrication
- Electrode Cutting and Structuring
- Precision Layer Removal for Additive Manufacturing

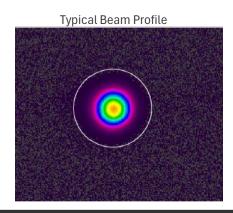
#### **FEATURES**

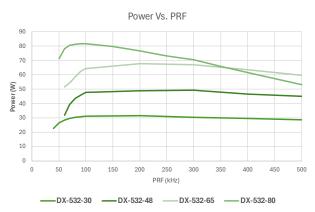
- Up to ~800μJ Pulse Energy at 100 kHz
- True TEM<sub>00</sub> Output
- Short Pulse Widths
- Water Cooled
- Robust & Compact Form Factor
- Dynamic Pulse Energy Control PEC
- Position Synchronized Output PSO
- Power Monitoring and Self-Calibration



Specifications - DX Short Pulse S	Series					
	DX-532-30	DX-532-48	DX-532-65	DX-532-80		
Wavelength (nm)	532					
Average Power (W) @100kHz	30	48	65	80		
Pulse Energy (µJ) @100kHz	~500	~600	~700	~800		
Pulse Width	~10ns @ 50kHz		~14ns @ 100kHz	~20ns @ 100kHz		
Pulse repetition rate <sup>1</sup>	Single shot to 500 kHz (Option up to 1MHz)					
Pulse-to-pulse stability (% RMS) <sup>2</sup>	<2					
Long-term power stability (% RMS) <sup>3</sup>	<2					
Beam spatial mode & M <sup>2</sup>	TEM <sub>00</sub> - M <sup>2</sup> < 1.1 TEI		TEM <sub>00</sub> - N	<sub>00</sub> - M <sup>2</sup> < 1.2		
Beam divergence (nominal) (mrad)	~ 2.5					
Beam diameter <sup>4</sup> at exit (nominal) (mm)	~ 0.7		~1			
Beam roundness	~90%					
Beam pointing stability (µrad)	<25					
Polarization ratio	Vertical; >100:1  Operational Specifications and Characteristics					
Interface	RS232, Ethernet, Software GUI, External TTL Triggering					
Warm-up time	< 5 minutes from standby, <10 minutes from cold start					
Electrical requirement	100-240 V AC - 32 V DC, 16 A [ PSU Included]					
Line frequency (Hz)	50-60					
Power consumption (W)	~3	350	~400	~600		
Dimensions	16 x 7.5 x 3.75in [406.4 x 190.5 x 95.25mm]		18 x 7.5 x 3.75in [457.2 x 190.5 x 95.25mm]			
Weight	~29 lbs [~13.2kg]			~34.5lbs [15.6kg]		
	Environmental Requirements					
Ambient temperature <sup>2</sup>	Ambient 15°C to 30°C (59°F to 86°F) Operating Range					
	Relative humidity 0% to 80% max, non-condensing					
Storage conditions -	-10°C to 40°C; sea level to 12000 m					
	0% to 80% relative Humidity, non-condensing					
Cooling system	Water-Cooled					

[1.] Lower pulse repetition rates (down to < 30 kHz) performance achieved by pulse energy capping. [2.] Measured at ambient temperature ± 2°C. [3.] Measured over 8 hours ± 1°C.

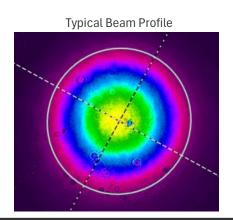


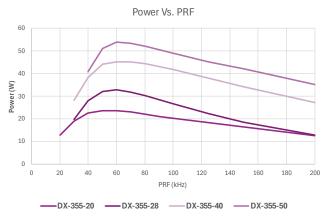




Specifications - DX Short Pulse S	eries					
	DX-355-20	DX-355-28	DX-355-40	DX-355-50		
Wavelength (nm)	355					
Average Power (W) @100kHz	20	28	40	50		
Pulse Energy (µJ) @50kHz	~400	~560	~800	~1000		
Pulse Width (ns) @50kHz	~12					
Pulse repetition rate <sup>1</sup>	Single shot to 300 kHz (Option up to >500kHz)					
Pulse-to-pulse stability (% RMS) <sup>2</sup>	<2					
Long-term power stability (% RMS) <sup>3</sup>	<2					
Beam spatial mode & M <sup>2</sup>	$TEM_{00} - M^2 \le 1.1$ $TEM_{00} - M^2 \le 1.2$					
Beam divergence (nominal) (mrad)	< 1.5					
Beam diameter <sup>4</sup> at exit (nominal) (mm)	~ 0.6		~ 2.5			
Beam roundness	~90					
Beam pointing stability (µrad)	<25					
Polarization ratio	Horizontal; >100:1					
	Operational Specifications and Characteristics					
Interface	RS232, Ethernet, Software GUI, External TTL Triggering					
Warm-up time	< 5 minutes from standby, <10 minutes from cold start					
Electrical requirement	100-240 V AC - 32 V DC, 16 A [ PSU Included]					
Line frequency (Hz)	50-60 Hz					
Power consumption (W)	~3	350	~400	~600		
Dimensions	18 x 7.5 x 3.75 [457.2 x 190.5 x 95.25mm]					
Weight	~34.5lbs [15.6kg]					
	Environmental Requirements					
Ambient temperature <sup>2</sup>	Ambient 15°C to 30°C (59°F to 86°F) Operating Range					
	Relative humidity 0% to 80% max, non-condensing					
Storage conditions —	-10°C to 40°C; sea level to 12000 m					
	0% to 80% relative Humidity, non-condensing					
Cooling system	Water-Cooled					

[1.] Lower pulse repetition rates (down to < 30 kHz) performance achieved by pulse energy capping. [2.] Measured at ambient temperature ± 2°C. [3.] Measured over 8 hours ± 1°C. [4.] Larger beam diameters at the exit (up to ~2.5 mm) are available with the expansion option.





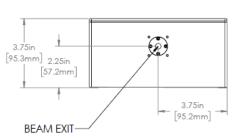


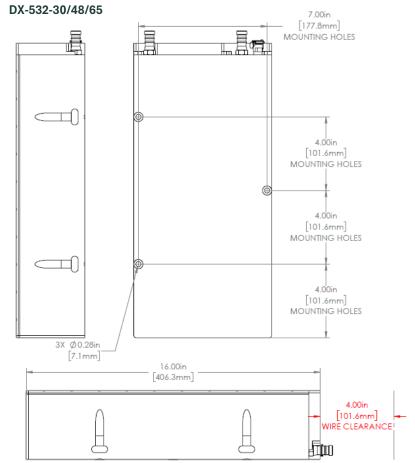


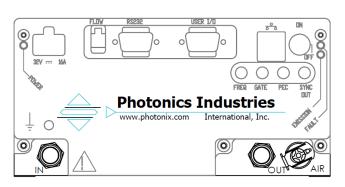
### **Dimensional Drawings**

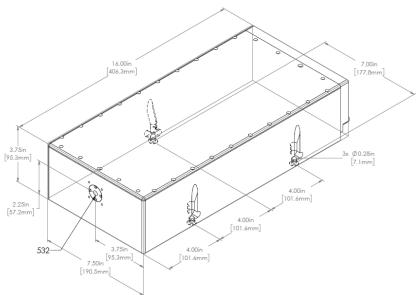
















Our ongoing policy is to improve the design and

specification of our products. The information provided is non-binding.

## DX-532-80, DX-355-20/28/40/50 7.00in - [177.8mm] MOUNTING HOLES 5.00in [127.0mm] MOUNTING HOLES [127.0mm] MOUNTING HOLES [101.6mm] 3X Ø0.28in MOUNTING HOLES [7.1mm] 7.50in [190.5mm] 4.00in 18.00in 101.6mm [457.2mm] WIRE CLEARANCE 3 75in [95.3mm] <sub>2.25in</sub> 57.2mm BEAM EXIT [84.8mm] EXPANDED BEAM EXIT (000**Photonics Industries** www.photonix.com International, Inc. BEAM EXIT EXPANDED BEAM EXIT-**Photonics Industries** © 2025 Photonics Industries International, Inc. International, Inc.

**Dimensional Drawings** 

Photonics Industries International Inc. is the pioneer of intracavity harmonic lasers and is at the forefront of developing, manufacturing, and marketing a wide range of nanosecond, sub-nanosecond, picosecond, and femtosecond lasers for the industrial, scientific, defense and medical industries.

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For more information www.photonix.com